

PVD Sputtered Films Available

Al₂O₃ (Reactive & Non-Reactive)
 AlCu (.5)
 AlCu (1)
 AlCu (4)
 AlMg
 AlSi (1)
 AlSi (.1)
 AlSi (2)
 AlSi (40ppm)
 AlSiCu (1/.5)
 AlSiCu (1/1)
 AlCuSi (2/1)
 Ag
 Al
 AlN (Reactive)
 Au
 C
 Co
 Cr
 Cr₂O₃ (Non-Reactive)
 CrSi
 Cr₂O₃TiO₂ (Non-Reactive)
 Cr₂O₃Al₂O₃ (Non-Reactive)
 Cu
 CuNi (60/40)
 CrMo (90/10)
 Fe

FeCo (60/40)
 FeCo (75/25)
 Ge
 GeSbTe
 ITO
 Mo
 MoSi (2)
 Nb
 Ni
 NiCr (80/20)
 NiCr (60/40)
 NiFe (19)
 NiP
 NiV (7)
 Pd
 Pt
 Si
 Si (Undoped)
 SiC
 SiCr (60/40)
 Si₃N₄ (Reactive)
 SiO₂ (Reactive & Non-Reactive)
 Sn
 Ta
 Ta₂O₅ (Non-Reactive)
 TaAl
 TaN (Reactive)

Ti
 TiN (Reactive)
 TiNi
 Ti₅Si₃
 TiO₂ (Reactive & Non-Reactive)
 W
 WSi (2.7)
 WTi (90/10)
 WTi (80/20)
 Zr
 ZrO₂ (Reactive & Non-Reactive)

